

**STD**  
**IUVSTA ECM 121**  
**October 24, 2015 in Holiday Inn Express, Morgan Hill, California, USA**  
**chaired by D. Ruzic, started 14.15 local time**

Draft Agenda

1. Opening and welcome
2. Attendance
3. Adoption of Agenda
4. Minutes of STD approval of ECM-120  
 (available on the IUVSTA web)
5. Divisional reports
  - Applied Surface Science Division, B. Tyler
  - Biointerfaces Division, G. Ceccone/A. Galtayries
  - Electronic Materials & Processes Division, R. H. Schwarz
  - Nanometer Structures Division, Ch. Teichert/S. Cohen
  - Plasma Science & Techniques Division, T. Gans
  - Surface Engineering Division, I. Petrov
  - Surface Science Division, M.-C. Asensio
  - Thin Film Division, Ch. Eisenmenger-Sittner
  - Vacuum Science and Technology Division, J. Hendricks

6. Proposals of Workshops, approval

Submitted by	Place/country	Date	Supp. IUVSTA div.	Title
Gao-Yu Hsiung	Hsinchu (Taiwan)	October 24 - 28 2016	VSTD	Workshop for the Ultra Low Emittance Light Source Vacuum Systems

7. TTC/TSC proposals, approval

Type of action	Submitted by	Place/country	Date	Supp. IUVSTA div.	Title
Short Training course	J. Bhatti	IVI (NINVASt), Islamabad, Pakistan	November 17-19 2015	SED, TFD, PST, ASSD	Vacuum, Coating and Nanotechnology
Technical Training Course	S. Novák	Boretice, (CZ)	May 30 – June 2 2016	VSTD	Low Pressure Plasma Processes and Technology

8. Any Other Business
9. Closing Remarks
- Adjourn

David Ruzic  
 STD Director